

Figure 1 V-I characteristics of *a*-Si:H(*p*)/*a*-BC:H(*n*) (left vertical axis) and *c*-Si(*p*)/*a*-BC:H(*n*) (right vertical axis) devices

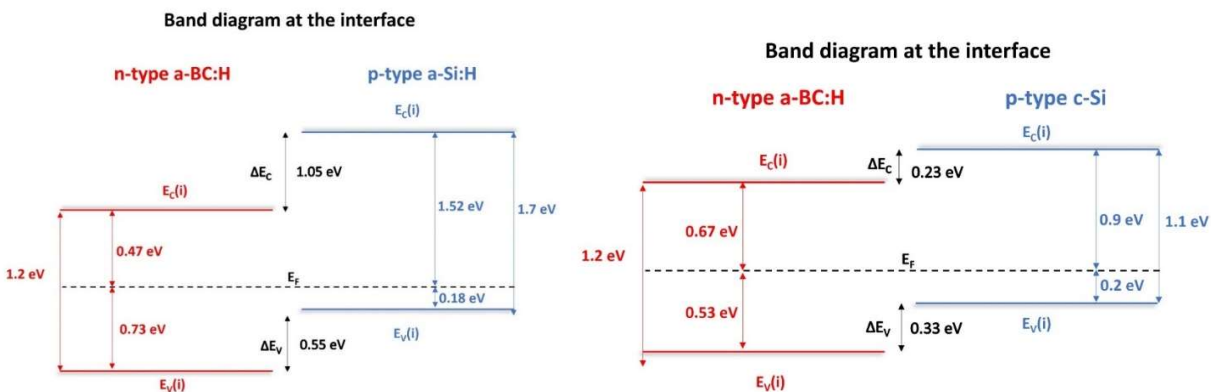


Figure 2 The *a*-BC:H(*n*)/*a*-Si:H(*p*) heterojunction band diagram at the interface (left) and the *a*-BC:H(*n*)/*c*-Si(*p*) heterojunction band diagram at the interface (right)

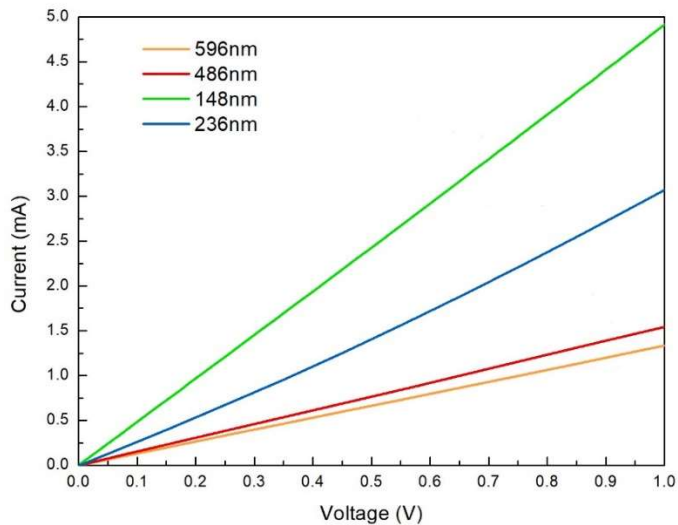


Figure 3 Ohmic V-I characteristics of Ti/*a*-BC:H(*n*)/Ti structures of varying *a*-BC:H(*n*) thicknesses